L Number	Hits	Search Text	DB	Time stamp
2	0	5482612.pn. and (polymer or LCP)	USPAT	2003/11/10
1	1	5482612.pn.	USPAT	2003/11/10
3	1224	((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and semiconductor	USPAT	09:50 2003/11/10 13:40
4	961	(((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and	USPAT	2003/11/10
5	861	<pre>semiconductor) and (substrate or wafer) ((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and semiconductor) and (substrate or wafer))</pre>	USPAT	2003/11/10
6	278	and @ay<=2000 ((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and semiconductor) and (substrate or wafer))	USPAT	2003/11/10
7	496	and @ay<=2000) and plasma ((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and plasma and	USPAT	2003/11/10 10:26
8	437	<pre>(chamber or apparatus) (((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000</pre>	USPAT	2003/11/10 10:25
9	312	((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000) and (aluminum or alumina)	USPAT	2003/11/10
10	175	(((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000) and (aluminum or alumina)) and semiconductor	USPAT	2003/11/10 10:27
11	496	((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)	USPAT	2003/11/10 10:45
12	367	(((liquid ad) (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and (aluminum or alumina)	USPAT	2003/11/10 10:26
13	175	and (arthurm of arthurm) ((((iquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and (aluminum or alumina)) and semiconductor and @ay<=2000	USPAT	2003/11/10
15	0	(Vectra adj IMP) and (liquid adj (crystal or crystalline) adj (polymer or polymeric))	USPAT	2003/11/10
16	9	Vectra adj IMP	USPAT	2003/11/10
17	407	((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) same (chamber or apparatus)	USPAT	2003/11/10
18	49	(((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar)	USPAT	2003/11/10 10:32
19	235	same (chamber or apparatus)) and plasma ((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and	US-PGPUB; EPO; JPO; DERWENT	2003/11/10
20	31	<pre>plasma and (chamber or apparatus) (((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000</pre>	DERWENT US-PGPUB; EPO; JPO; DERWENT	2003/11/10 13:17
21	. 4	"0433778"	US-PGPUB; EPO; JPO; DERWENT	2003/11/10
22	0	"0433778"	EPO	2003/11/10
23	868	Bayer.in.	ЕРО	2003/11/10 11:08

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24	10	Bayer.in. and Hermann	EPO	2003/11/10 11:16
25	4801	plasma and ((chamber or apparatus) same (LCP or polymer))	USPAT	2003/11/10
26	2378	plasma and ((chamber or apparatus) with (LCP or polymer))	USPAT	2003/11/10
27	1036	(plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor	USPAT	2003/11/10 11:17
28	950	((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and Gay<-2000	USPAT	2003/11/10
29	730	((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating or surface))	USPAT	2003/11/10 11:18
30	449	(((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))	USPAT	2003/11/10 16:40
31	327	<pre>((((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))) and (aluminum or alumina)</pre>	USPAT	2003/11/10 11:19
32	314	(((((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))) and (aluminum or alumina) not	USPAT	2003/11/10 11:19
	7.70	((((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000) and (aluminum or alumina)) and semiconductor)		
33	1	6120854.pn.	USPAT	2003/11/10
34	10	("4336276" "4505945" "5019686" "5144110" "5206259" "5216092" "5296542" "5434210" "5530050" "5834064").PN.	USPAT	2003/11/10 13:35
35	113		USPAT	2003/11/10 16:41
37	109	(((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar)	USPAT	2003/11/10 16:29
38	38	<pre>same alumina) and @ay<=2000 (({(liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) same alumina) and @ay<=2000) and filler</pre>	USPAT	2003/11/10 14:08
39	31	with (LCP or polymer))) and semiconductor) and filter (((plasma and (chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))) and filler	USPAT	2003/11/10 16:39
40	1663	((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and filler	USPAT	2003/11/10 16:41
41	428	((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) same filler	USPAT	2003/11/10 16:41
42	39	(((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) same filler) and plasma	USPAT	2003/11/10 16:41
-	1168	Same liller; and plasma ((liquid adj crystal\$5 adj polymer) or LCP) and semiconductor	USPAT	2003/11/10
-	312	(((liquid adj crystal\$5 adj polymer) or LCP) and semiconductor) and plasma	USPAT	2003/11/03

-	302		USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and		16:09
	1	(substrate or wafer)		[
-	274	((((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and		16:09
		@ay<=2000		10.05
-	240		USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and	001111	16:14
		@ay<=2000) and (aluminum or alumina)		10.14
1 -	226	((((((liquid adj crystal\$5 adj polymer)	USPAT	2002 (11 (02
		or LCP) and semiconductor) and plasma)	USPAI	2003/11/03
		and @ay<=2000) and (aluminum or alumina))	i	16:21
		and eay(-2000) and (aluminum or alumina))		
1		and (chamber or apparatus or (focus adj		
	3.5	ring) or plate or pedestal)		
-	36	((((())) OLYDOXXVO GG POLYMEL)	USPAT	2003/11/03
		or LCP) and semiconductor) and plasma)		16:48
		and @ay<=2000) and (aluminum or alumina))		1
		and (((liquid adj crystal\$5 adj polymer)		9
	1	or LCP) same (chamber or apparatus or		
		(focus adj ring) or plate or pedestal))	1	
-	965	(((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/03
		LCP) same (chamber or apparatus or (focus	001111	16:48
	1	adj ring) or plate or pedestal))	1	1-3.10
-	57	((((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/03
		LCP) same (chamber or apparatus or (focus	USFAI	
		adj ring) or plate or pedestal))) and		16:51
		somiconductor and (atab to the birth		1
_	52	semiconductor and (etch or etching)		1
	32	((((d	USPAT	2003/11/03
		LCP) same (chamber or apparatus or (focus		16:51
		adj ring) or plate or pedestal))) and		1
		semiconductor and (etch or etching)) and	Į.	
		@ay<=2000		
-	5181	((liquid adj (crystal or crystalline) adj	USPAT	2003/11/05
		polymer) or LCD) and (etch or etching)		09:58
-	2445	(((liquid adj (crystal or crystalline)	USPAT	2003/11/05
1		adj polymer) or LCD) and (etch or		09:58
		etching)) and plasma		1
-	2182	((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:58
f		etching)) and plasma) and @ay<=2000		03.30
-	895	(((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or	OSFAI	09:51
		etching)) and plasma) and @ay<=2000) and		03:21
		wall	1	
_	38	(((((liquid adj (crystal or crystalline)	****	0000/11/00
	30	adi polyment an ICD)	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:52
		etching)) and plasma) and @ay<=2000) and	1	
	1	((wall or coating) with (LCP or (liquid	f	
	1	adj (crystal or crystalline) adj		
		polymer)))		
-	928	((liquid adj (crystal or crystalline) adj	USPAT	2003/11/05
		polymer) or LCP) and (etch or etching)		09:58
-	308	(((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCP) and (etch or		09:58
		etching)) and plasma		
-	277	((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCP) and (etch or		09:58
		etching)) and plasma) and @ay<=2000		33.30
-	48	(((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
	1	adj polymer) or LCP) and (etch or	VOFAL	
		etching)) and plasma) and @ay<=2000) and		11:34
		((wall or coating) same (LCP or (liquid		
1	1	adj (crystal or crystalline) adj		
	1	polymer)))		
_	1	6326307.pn.	******	0000/00/00
1		0320307.pm.	USPAT	2003/11/05
_	2	5992245 mm == 5400502		11:35
	4	5882245.pn. or 5488603.pn.	USPAT	2003/11/05
L				12:52